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Supporting Information for

## Janus Monolayer of WSeTe, A New Structural Phase Transition Material Driven by Electrostatic Gating

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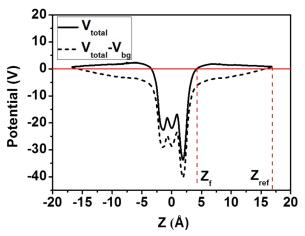


Figure S1 Plane-averaged electrostatic potential along the vacuum direction Z of a charged (0.05 e per formula unit) Janus monolayer of WSeTe in the H phase. The black solid line shows the total potential  $V_{total}$ , including the potential arising from the charged monolayer and that from the uniform compensating background charge  $V_{bg}$ . The dashed line shows the potential of the charged monolayer only,  $V_{total} - V_{bg}$ . The red line denotes the Fermi level  $\mu_F$  of a charged system.

In a DFT calculation of a charged system with periodic boundary conditions, a homogeneous background charge is automatically introduced to compensate for the excess charge. We choose the middle plane of the vacuum slab as the reference plane. The reference plane is parallel to the monolayer, at a distance zref away from the Janus monolayer center. The energy of the charged monolayer Emo(Q, zref) can be calculated by,<sup>1</sup>

$$Emo(Q, zref) = E0 + \int_{0}^{Q} \Delta V(Q', zref) dQ'$$
(1)

where E0 is the ground-state energy of an electrically neutral monolayer, the integral is the energy of moving charge Q' from the reference plane to the Fermi level of the monolayer, and  $\Delta V(Q',zref)$  is the electronic potential difference between the reference plane zref and the surface of the monolayer defined as  $z_f$ . As illustrated in Figure S1,  $z_f$  is the distance at which the total potential is equal to the Fermi level.

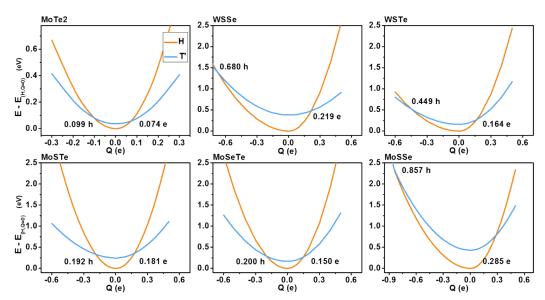


Figure S2 Energies of MoTe<sub>2</sub> and Janus monolayer MXY except for WSeTe in the H and T'phases respectively, as a function of the excessive charge.

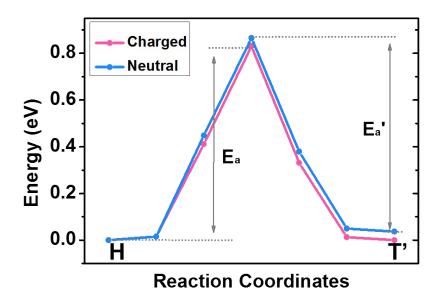


Figure S3 The NEB results of the phase transition barriers between T' and H phases of MoTe<sub>2</sub> monolayer.  $E_a = 0.833$  eV/f.u. is the kinetic barrier for the H-to-T' phase transition with MoTe<sub>2</sub> in the charged state (0.074 e/f.u. or 0.099 h/f.u. where H and T' phases are equally stable), and  $E_a$ ' = 0.83 eV is the reversed T'-to-H transition barrier with MoTe<sub>2</sub> in the charge neutral state. These two barriers are related to the kinetics of the structural phase transition modulated by electrostatic doping in the FET device.

**Table S1** Structural parameters and the total energy of MoTe<sub>2</sub> and six Janus monolayers of TMDCs in the H and T' phases, respectively. **a** and **b** are the lattice

parameters of the unit cell,  $\mathbf{h}$  is the thickness of monolayers, referring to the height between the top-layer and bottom-layer chalcogen atoms,  $\Delta E$  is the energy difference between H and T' phases,  $E_{T'}$  -  $E_{H.}$ 

		a /Å	b/Å	Height (h) /Å	E /eV	ΔE / meV
MoTe2	Н	3.522	\	3.620	-18.635	36
	T'	3.451	6.297	4.135	-18.598	
MoSSe	Н	3.232	\	3.239	-21.181	432
	T'	3.199	5.837	3.609	-20.749	
MoSTe	Н	3.339	\	3.385	-20.138	247
	T'	3.308	6.036	3.787	-19.891	
MoSeTe	Н	3.406	\	3.620	-19.426	167
	T'	3.359	6.129	3.939	-19.259	
WSSe	Н	3.231		3.252	-23.135	586
	T'	3.233	5.801	3.633	-22.548	
WSTe	Н	3.340		3.396	-21.951	159
	T'	3.342	5.997	3.824	-21.792	
WSeTe	Н	3.405		3.502	-21.182	48
	T'	3.390	6.083	3.982	-21.134	

## Reference

(1) Li, Y.; Duerloo, K. A.; Wauson, K.; Reed, E. J. Structural Semiconductor-to-Semimetal Phase Transition in Two-Dimensional Materials Induced by Electrostatic Gating. *Nat Commun* **2016**, *7*, 10671.